Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	"6631062"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 08:36
L2	98	"5880925"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 08:37
L3	5	"588095".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 08:37
L4	2	"5880095"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 08:38
L5	98	"5880925"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 08:38
L6	2	"5880925".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 08:39
L7	14566	kumar.inv.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 08:39
L8	8	"6041938"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 09:11
L9	2261	(robot adj3 arm) same (gripper or clamp$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 08:51
L10	585	(robot adj3 arm) same (gripper or clamp$4) same (tilt$4 or rotat$4 or compliant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 08:52

L11	140	10 and (wafer or substrate or reticle or mask)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 09:01
L12	30	11 and (compliant or compliance)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 09:02
L13	11	"4788577"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 09:50
L14	14	"6184972"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 09:53
L15	2	"6184972".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 09:55
L16	163483	($6lithograph$4 or exposure) and (substrate or wafer or object) and (mask or reticle)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 09:57
L17	4302	16 and (((robot or transport$4 or transfer$4 or mov$4) adj4 (arm or device or element or structure)) near6 (wafer or substrate or object))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 09:59
L18	647	17 and (clamp$4 or grip$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:00
L19	1	18 and ((correct$4 or compensat$4 or adjust$4) near6 (tilt$4 or displacement or inclin$4) near6 (between) near6 (clamp$5 or grip$4) near6 (wafer or substrate or object))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:02
L20	2	18 and ((correct$4 or compensat$4 or adjust$4) near6 (tilt$4 or displacement or inclin$4) near6 (clamp$5 or grip$4) near6 (wafer or substrate or object))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:46

L21	38	18 and compliant	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 10:49
L22	47	18 and (flex$4 near5 (clamp$4 or grip$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:52
L23	47	22 and ($lithograph$4 or exposure)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:52
L24	47	23 and (substrate or wafer) and (reticle or mask)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:53
L25	23	24 and projection	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/09 10:54
L26	3	22 and (robo$4) adj3 (arm or transport$4 or transfer$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:55
L27	176	18 and (robo$4) adj3 (arm or transport$4 or transfer$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:57
L28	1	27 and ((compensat$4) near6 (tilt$4 or displacement) near6 (clamp$4 or grip$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:58
L29	2	27 and ((compensat$4 or correct$4 or adjust$4 or reduc$4 or avoid$4) near6 (tilt$4 or displacement) near6 (clamp$4 or grip$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/09 10:58